Identification of eta-carbide in a commercial Ni—Mo alloy (Hastelloy® alloy B-2)

The commercial Hastelloy^{*} alloy B-2 is essentially a Ni–Mo alloy where the carbon content is kept at a low level in order to achieve an acceptable corrosion resistance in the as-welded condition [1]. Recently, a minute amount of the intermetallic NiMo (δ -phase) has been identified in a heat containing less than 0.002 weight per cent carbon [2]. It is the objective of this note to report on the identification by electron diffraction and microscopy of a grain boundary eta-carbide phase in aged samples of a heat containing 0.002 weight per cent carbon. Table I shows the chemical composition of the heat investigated. The heat treatment consisted of annealing at 1065° C followed by water quenching. Annealed samples were then aged at 800° C for 1 to 100 h. Thin foils for transmission electron microscopy and diffraction were prepared by jet polishing in a solution consisting of one part HNO₃ and three parts methanol at about -30° C. All the foils were examined in a Philips 300EM operated at 100 kV.

Fig. 1 shows a number of selected area diffraction patterns derived at different tilts from the grain boundary particle shown in Fig. 2. All of these patterns were consistently indexed in terms of a face-centred cubic lattice. The matrix phase (f c c with a = 0.3610 nm) was used as an internal



Figure 1 Selected area electron diffraction patterns derived from a grain boundary carbide particle. (a) $[1\overline{1}\overline{1}]$, (b) $[\overline{1}03]$, (c) $[0\overline{1}5]$ and (d) $[\overline{3}3\overline{2}]$.

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Figure 2 Electron micrographs of the same grain boundary carbide particle as in Fig. 1 (beam parallel to $[1\overline{1}\overline{1}]$). (a) Bright-field image and (b) dark-field image with a (220) particle reflection.

TABLE I Chemical composition in weight per cent С Ni Mo Fe Cr Co Si v 70.42 29.92 0.93 0.64 < 0.10< 0.02 < 0.01 0.002

standard in measuring the camera constant. From the observed *d*-spacings, the lattice constant of the grain boundary phase was calculated to be 10.86 ± 0.01 Å (1.086 nm). This suggests that this phase is an eta-carbide of the form M_{12} C such as that found in the ternary Ni-Mo-C system [3, 4] and in Hastelloy alloy N [5]. The present result and that reported earlier [2] concerning the presence of δ -NiMo in Hastelloy alloy B-2 seem to indicate that M_{12} C and δ -NiMo may co-exist, as has been concluded by Heijwegen and Rieck [4] in the case of the Ni-Mo-C ternary system.

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About the origin of magnetoresistance in relatively thin metal films

It has previously been [1] shown that the transport properties of a thin metallic film placed in a transverse magnetic field (perpendicular to its plane) can be, as in the absence of a magnetic field, described in terms of a mean free path model [1, 2] which takes into account the background scattering and the scattering at external surfaces [3, 4], i.e. the scatterings of the Fuchs-Sondheimer conduction model [4]. In this model the film conductivity, $\sigma_{\rm F}$, and the Hall coefficient, $R_{\rm HF}$, are evaluated by means of the following 2. H. M. TAWANCY, J. Mater. Sci. 15 (1980) 2597.

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analytical expressions [1]

and

(1)

$$R_{\rm HF}/R_{\rm H0} = B[A^2 + \alpha^2 B^2]^{-1}, \qquad (2)$$

where

$$A = \frac{3}{2} \left\{ -\frac{1}{2}\mu + \mu^2 + \frac{\mu}{2} (1 - \mu^2 + \alpha^2 \mu^2) \times \ln \left[\frac{(1 + \mu^{-1})^2 + \alpha^2}{1 + \alpha^2} \right] - 2\alpha\mu^3 \arctan \left[\frac{\alpha}{\mu} \frac{1}{(\alpha^2 + 1 + \mu^{-1})} \right] \right\} (3)$$

 $\sigma_{\rm F}/\sigma_0 = [A^2 + \alpha^2 B^2]A^{-1}$

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